

I. Amendments to the Specification:

Please replace the first paragraph on page 1, at lines 3-6, with the following paragraph:

This application is a divisional of U.S. Application No. 10/400,073, filed on March 27, 2003, now allowed, which is a divisional of U.S. Application No. 10/241,513 filed on September 12, 2002, issued as U.S. Patent No. 6,566,379, which is a divisional of U.S. Application No. 10/012,445 filed on December 12, 2001, issued as U.S. Patent No. 6,472,399, which is a divisional of U.S. Application No. 09/827,292, filed on April 6, 2002, issued as U.S. Patent No. 6,350,764, which is a divisional of U.S. Application No. 09/482,540 filed on January 14, 2000, issued as U.S. Patent No. 6,245,763, which is a divisional of U.S. Application No. 09/199,167 filed on November 25, 1998, issued as U.S. Patent No. 6,037,356, which claims the benefit under 35 U.S.C. § 119(e) of U.S. Provisional Application No. 60/079,107, filed March 23, 1998, Application No. 60/067,324, filed December 5, 1997, and Application No. 60/066,475, filed November 26, 1997. The entirety of each of these application is incorporated by reference herein.

Please replace the paragraph at page 11, lines 22-25, with the following paragraph:

Preferred compounds are those where R^3 , R^4 and R^5 are independently hydrogen, C_{1-4} alkyl, C_{3-7} cycloalkyl, C_{6-14} aryl, especially C_{6-10} aryl, C_{6-10} ar(C_{1-4})alkyl, trifluoromethyl, halogen, hydroxyalkyl, cyano, nitro, ~~carboxamide~~ carboxamido, carboxy, alkoxycarbonyl, carboxymethyl, alkoxycarbonylmethyl, or cycloalkyloxycarbonyl.

Please replace the paragraph at page 12, lines 1-3, with the following

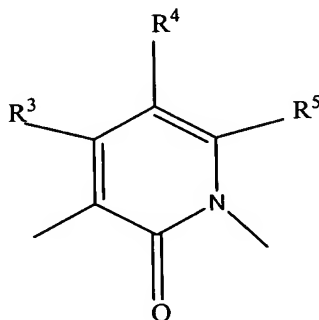
paragraph:

Useful values of R^3 , R^4 and R^5 include hydrogen, methyl, ethyl, propyl, chloro, bromo, trifluoromethyl, hydroxymethyl, methoxy, ethoxy, ~~carboxamide~~ carboxamido, nitro, phenyl, cyclopropyl, hydroxy, isopropyl, methoxycarbonyl, ethoxycarbonyl and benzyl.

Please replace the paragraph at page 12, lines 9-17, with the following

paragraph:

A particularly preferred Het, when R^3 and R^4 are independently selected to be hydrogen or methyl, is



wherein R^5 is selected from the group consisting of hydrogen, methyl, ethyl, propenyl, allyl, propyl, isopropyl, butyl, R-sec-butyl, S-sec-butyl, isobutyl, 1-pentyl, R-2-pentyl, S-2-pentyl, 3-pentyl, S-1-(2-methyl)-butyl, R-2-(3-methyl)-butyl, 1-(3-methyl)-butyl, R-1-(2-methyl)-butyl, cyclopentyl, ~~2-pyrrolyl, 3-pyrrolyl~~, 2-pyrrolyl, 3-pyrrolyl, 1-hexyl, S-2-hexyl, R-2-hexyl, R-3-hexyl, and S-3-hexyl. A particularly preferred Het according to this aspect has hydrogen, methyl, ethyl, propyl or isopropyl as R^5 .